



## IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

re application of:

**Tzeng** 

**Group Art Unit:** 

1762

Serial No:

09/501,114

**Examiner:** 

Wesley D. Markham

Filed:

February 10, 2000

Docket No.: 220101-1010

For:

Method of Plasma Enhanced **Chemical Vapor Deposition** 

of Diamond

## RESPONSE TO OFFICE ACTION

**Assistant Commissioner for Patents** Washington, D.C. 20231

Sir:

TO TOURS TO THE TOURS TOURS TO THE Office Action mailed June 27, 2002 (Paper No. 11) has been carefully considered. In response thereto, please enter the following amendments and consider the following remarks.

## AUTHORIZATION TO DEBIT ACCOUNT

It is not believed that extensions of time or fees for net addition of claims are required, beyond those, which may otherwise be provided for in documents accompanying this paper. However, in the event that additional extensions of time are necessary to allow consideration of this paper, such extensions are hereby petitioned under 37 C.F.R. § 1.136(a), and any fees required therefor (including fees for net addition of claims) are hereby authorized to be charged to deposit account no. 20-0778.

## **CERTIFICATE OF MAILING (37 CFR 1.8)**

I hereby certify that this paper (along with any paper referred to as being attached or enclosed) is being deposited with the United States Postal Service on the date shown below with sufficient postage as first class mail in an envelope to the: Assistant Commissioner For Patents, Washington, D.C.

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